AMENDMENTS TO THE ABSTRACT

Docket No.: 20289/0205086-US0

Please substitute the following paragraph(s) for the abstract now appearing in the currently filed specification:

--Disclosed is a photosensitive resin composition comprising a resin (A) soluble in an aqueous alkaline solution, a crosslinking agent (B), a photopolymerization initiator (C) and a curing agent (D) wherein the curing agent (D) is an epoxy compound obtained by glycidylating a compound containing not less than 80% of a tetraphenylethane derivative represented by the following formula (1).

In the formula, R_1 to R_8 independently represents a hydrogen atom, a C_1 - C_4 alkyl group or a halogen atom.--